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EXPRESS MAIL NO. EL 872037758 US

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Reissue Patent Application:

Applicants : Trung T. Doan and Gurtej S. Sandhu  
Assignee: : Micron Technology, Inc.  
Filed : December 19, 2001  
For : POLISHING PAD REFURBISHER FOR IN SITU, REAL-TIME CONDITIONING  
AND CLEANING OF A POLISHING PAD USED IN CHEMICAL-MECHANICAL  
POLISHING OF MICROELECTRONIC SUBSTRATES  
Docket No. : 500300.02

Corresponding Issued U.S. Patent:

Patent No. : 6,004,196  
Issued : December 21, 1999  
Application No. : 09/032,230  
Filing Date : February 27, 1998  
Examiner : William Hong  
Art Unit : 3725

BOX REISSUE  
Commissioner for Patents  
Washington, D.C. 20231

PRELIMINARY AMENDMENT

Sir:

Please accept the request for a reissue of U.S. Patent No. 6,004,196, filed herewith. Prior to conducting the examination of the reissue claims, please amend the reissue application as follows:

Please add the following new claims 31-53: